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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/634,212	08/05/2003	Karen Signorini	MICRON.249C1DV1	6861
20995 7	7590 03/31/2005		EXAMINER	
	ARTENS OLSON & B	DOLAN, JENNIFER M		
2040 MAIN STREET FOURTEENTH FLOOR			ART UNIT	PAPER NUMBER
IRVINE, CA 92614			2813	

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)			
Office Action Summary		10/634,212	SIGNORINI, KAREN			
		Examiner	Art Unit			
		Jennifer M. Dolan	2813			
Ti Period for R	he MAILING DATE of this communication appo eply	ears on the cover sheet with the co	orrespondence address			
THE MAI - Extension: after SIX ( - If the period - If NO period - Failure to Any reply	TENED STATUTORY PERIOD FOR REPLY LING DATE OF THIS COMMUNICATION. s of time may be available under the provisions of 37 CFR 1.13 (6) MONTHS from the mailing date of this communication. od for reply specified above is less than thirty (30) days, a reply od for reply is specified above, the maximum statutory period w reply within the set or extended period for reply will, by statute, received by the Office later than three months after the mailing tent term adjustment. See 37 CFR 1.704(b).	6(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days ill apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	ely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).			
Status						
1)⊠ Re	sponsive to communication(s) filed on 14 Ma	arch 2005.				
2a)⊡ Thi	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.					
3) <u></u> Sin	ce this application is in condition for allowan	ce except for formal matters, pro	secution as to the merits is			
clo	sed in accordance with the practice under E.	x <i>parte Quayle</i> , 1935 C.D. 11, 45	3 O.G. 213.			
Disposition	of Claims					
4)⊠ Cla	nim(s) 11-18 is/are pending in the application	!•				
•	Of the above claim(s) is/are withdraw					
5)⊠ Cla	nim(s) <u>12 and 14-16</u> is/are allowed.					
6)⊠ Cla	im(s) 11,13 and 17 is/are rejected.					
7)⊠ Cla	im(s) <u>18</u> is/are objected to.					
8)∏ Cla	im(s) are subject to restriction and/or	election requirement.				
Application	Papers					
9)[] The	specification is objected to by the Examiner					
10) <u></u> The	drawing(s) filed on is/are: a) acce	epted or b) objected to by the E	xaminer.			
App	olicant may not request that any objection to the o	lrawing(s) be held in abeyance. See	37 CFR 1.85(a).			
Rep	placement drawing sheet(s) including the correction	on is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).			
11) <u></u> The	oath or declaration is objected to by the Exa	aminer. Note the attached Office	Action or form PTO-152.			
Priority unde	er 35 U.S.C. § 119	•				
	nowledgment is made of a claim for foreign ∣ II b)⊡ Some * c)□ None of:	priority under 35 U.S.C. § 119(a)	-(d) or (f).			
1.[	1. Certified copies of the priority documents have been received.					
2.[	2. Certified copies of the priority documents have been received in Application No					
3.	<b>-</b>	•	d in this National Stage			
	application from the International Bureau					
* See	the attached detailed Office action for a list of	of the certified copies not received	d.			
Attachment(s)	Deferences Cited (DTO 200)	<b>4.</b> []				
	References Cited (PTO-892)  Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary ( Paper No(s)/Mail Da	`			
3) Information	n Disclosure Statement(s) (PTO-1449 or PTO/SB/08)	5) Notice of Informal Pa	atent Application (PTO-152)			
Paper Not	(s)/Mail Date <u>3/14/05</u> .	6)				

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#### **DETAILED ACTION**

#### Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on 3/14/05 has been entered.

## Information Disclosure Statement

2. The information disclosure statement (IDS) submitted on 3/14/05 was filed with an RCE on 3/14/05. The submission is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement is being considered by the examiner.

## Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless –

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 4. Claims 11, 13, and 17 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent No. 6,358,756 to Sandhu et al. (cited by applicant).

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The applied reference has a common assignee with the instant application. Based upon the earlier effective U.S. filing date of the reference, it constitutes prior art under 35 U.S.C. 102(e). This rejection under 35 U.S.C. 102(e) might be overcome either by a showing under 37 CFR 1.132 that any invention disclosed but not claimed in the reference was derived from the inventor of this application and is thus not the invention "by another," or by an appropriate showing under 37 CFR 1.131.

Regarding the claims, Sandhu discloses a magnetic memory device (figure 5) formed on a substrate (10-12) having a conductor (16) formed therein (figure 5), comprising: a pinned layer (20) magnetized in a first direction (column 4, lines 24-35) and patterned to a first width (figure 2); a sense layer (28) that can selectively be magnetized in the first direction or a direction opposite the first direction so as to change the net resistivity or the magnetic memory device (column 1, lines 20-35; column 5, lines 1-52), wherein the sense layer is patterned to a second width less than the first width to reduce magnetic coupling between the pinned and sense layers (figure 5, column 5, lines 1-52); and a spacer (26) that is positioned about the outer lateral edge of the sense layer (figure 5) and interposed between the outer lateral edges of the sense and pinned layers (figure 5), wherein the spacer is formed of silicon nitride (column 5, lines 1-10). It is inherently the case that the sense layer can be varied by the application of an external field to thereby change the magnetic characteristics of the sense and pinned layers, since the sense layer is not "fixed" by a permanent magnet or AFM, and thus is free to rotate.

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### Allowable Subject Matter

- 5. Claims 12 and 14-16 are allowed.
- 6. Claim18 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter:

The primary reason for allowability is that the only prior art that teaches the use of SiN, SiC, or a-C spacer layers interposed between the outer lateral edges of a pinned layer and a sense layer patterned to a smaller width than the pinned layer shares a common assignee with the present application and only qualifies as prior art under 35 U.S.C. 102 (e). Hence, U.S. Patent No. 6,358,756 to Sandhu et al., which was cited by the applicant in the IDS filed 3/14/05 and which shares a common assignee with the present application, is not usable for 103(a) rejections (see MPEP § 706.02(l)(1) and § 706.02(l)(2)). Sandhu fails to disclose the claimed elements of a tunnel layer patterned to the same width as the pinned layer (claim 12), or a sense layer formed of NiFeCo (claim 18).

Other than the Sandhu reference, the prior art fails to teach the use of a SiN, SiC, or amorphous –Carbon sidewall spacer in the claimed structure, but rather teaches the use of aluminum oxide or silicon dioxide. Since the claimed sidewalls are used as a mask structure during the patterning of the tunnel oxide layer and pinned layer in the present invention, the sidewall material must be chosen to have high etch selectivity with respect to the tunnel oxide and pinned layer, as well as fulfill the function of reducing magnetic coupling between the sense and pinned layers. Hence, the selection of materials such as SiN or SiC is critical in the present

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invention. It is the examiner's opinion that a person having ordinary skill in the art would have

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found no motivation in the prior art to use SiC or SiN as a sidewall spacer interposed between a

pinned layer and a narrower sense layer, but rather would have simply used the conventional

materials taught in the prior art.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Jennifer M. Dolan whose telephone number is (571) 272-1690.

The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number

for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about the PAIR

system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR

system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jennifer M. Dolan

Examiner

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jmd

CARL WHITEHEAD, JR.

SUPERVISORY PATENT EXAMINER

**TECHNOLOGY CENTER 2800**